

Outline:

p-n Junctions

p-type material (dopant is electron acceptor)

$$p_v \approx \frac{N_A}{n_i^2}$$

$$n_c \approx \frac{n_i^2}{N_A}$$

$$F = E_v + \frac{E_g}{2} + \frac{3}{4}k_B T \ln\left(\frac{m_v^*}{m_c^*}\right) - k_B T \ln\left(\frac{N_A}{n_i}\right)$$

n-type material (dopant is electron donor)

$$p_v \approx \frac{n_i^2}{N_D}$$

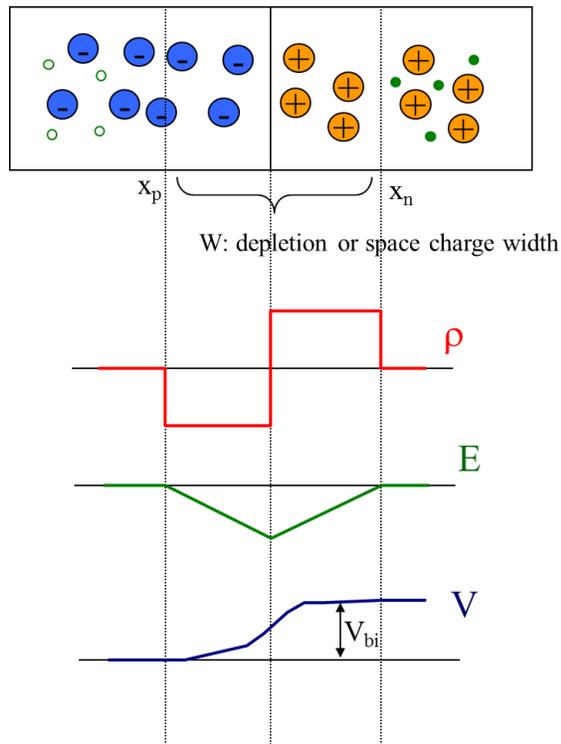
$$n_c \approx N_D$$

$$F = E_v + \frac{E_g}{2} + \frac{3}{4}k_B T \ln\left(\frac{m_v^*}{m_c^*}\right) + k_B T \ln\left(\frac{N_D}{n_i}\right)$$

When p-type and n-type materials are brought together, they form a ***p-n*** junction. Immediately upon joining, holes will flow from p-type to n-type and electrons from n-type to p-type until an equilibrium is reached when the chemical potential/Fermi energies of each side are equal. This junction results in a redistribution of charge and thus the creation of an electric field being built into the system in a region called the depletion region.

Recall: $E(x) = \int \frac{\rho(x)}{\epsilon_r \epsilon_0} dx$ & $V(x) = -\int E(x) dx$

The built in potential results in no current flowing. To make current flow, an applied forward bias must be applied to the system for current to flow.



$$qV_{BI} = E_{Fn} - E_{Fp} = k_B T \ln \left(\frac{N_D N_A}{n_i^2} \right)$$

$$W = x_p + x_n = \sqrt{\frac{2\epsilon_r \epsilon_0 V_{BI} N_A + N_D}{q N_A N_D}}$$

$$x_p = \sqrt{\frac{2\epsilon_r \epsilon_0 V_{BI} N_D}{q N_A (N_A + N_D)}}$$

$$x_n = \sqrt{\frac{2\epsilon_r \epsilon_0 V_{BI} N_A}{q N_D (N_A + N_D)}}$$

$$N_A x_p = N_D x_n$$

e.g. Variable band gap semiconductor.

You are working on creating light absorbing **p-n** junction devices and have found a material semiconducting alloy whose band gap energy can be controlled with an external magnetic flux B . You have empirically determined that $E_g = 4.4 \text{ eV} - 0.3 \frac{\text{eV}}{\text{T}^2} B^2$, where B is measured in Tesla T. The effective mass of the electrons in the system are $\sim 0.5 m_e$ and the effective mass of the holes in the system are $\sim 1.5 m_e$. The system is at room temperature $T = 300 \text{ K}$.

(a) What magnetic flux must you apply to get an intrinsic carrier concentration of 10^{15} cm^{-3} ?

$$n_c(T)p_v(T) = N_c(T)P_v(T)e^{\frac{-E_g}{k_B T}}$$

$$n_c = p_v = n_i$$

$$N_c(T) \cong \frac{1}{4} \left(\frac{2m_c^* k_B T}{\pi \hbar^2} \right)^{\frac{3}{2}}$$

$$P_v(T) \cong \frac{1}{4} \left(\frac{2m_v^* k_B T}{\pi \hbar^2} \right)^{\frac{3}{2}}$$

$$n_i^2 = \frac{1}{4} \left(\frac{2m_c^* k_B T}{\pi \hbar^2} \right)^{\frac{3}{2}} \frac{1}{4} \left(\frac{2m_v^* k_B T}{\pi \hbar^2} \right)^{\frac{3}{2}} e^{\frac{-E_g}{k_B T}}$$

$$\frac{16n_i^2}{(m_c^* m_v^*)^{\frac{3}{2}} \left(\frac{2k_B T}{\pi \hbar^2} \right)^3} = e^{\frac{-E_g}{k_B T}}$$

$$E_g = -k_B T \ln \left(\frac{16n_i^2}{\left(\frac{m_c^* m_v^*}{m_e^2} \right)^{\frac{3}{2}} \left(\frac{2m_e k_B T}{\pi \hbar^2} \right)^3} \right)$$

$$E_g = \frac{3}{2} k_B T \ln \left(\frac{m_c^* m_v^*}{m_e^2} \right) + k_B T \ln \left(\frac{\left(\frac{2m_e k_B T}{\pi \hbar^2} \right)^3}{16n_i^2} \right)$$

$$4.4 \text{ eV} - 0.3 \frac{\text{eV}}{\text{T}^2} B^2$$

$$= 8.62 \times 10^{-5} \frac{\text{eV}}{\text{K}} 300 \text{ K} \left(\frac{3}{2} \ln(1.5 * 0.5) + \ln \left(\frac{(2 * 9.11 \times 10^{-31} \text{ kg } 1.38 \times 10^{-23} \frac{\text{J}}{\text{K}} 300 \text{ K})^3}{\pi^3 1.05 \times 10^{-34} \text{ J}^6 \text{ s}^6 16 * 10^{42} \text{ m}^6} \right) \right)$$

$$B = 3.6 \text{ T}$$

- (b) What wavelength of photons does this magnetic flux correspond to as the maximum wavelength the system can absorb?

$$E_g = 4.4 \text{ eV} - 0.3 \frac{\text{eV}}{\text{T}^2} B^2 = 0.514 \text{ eV}$$

$$E_g = E = h\nu = \frac{hc}{\lambda}$$

$$0.514 \text{ eV} = 1240 \text{ eV} \frac{\text{nm}}{\lambda}$$

$$\lambda = 2414 \text{ nm}$$

This wavelength is in the infrared.

- (c) What is the location of the Fermi energy for this band gap at this applied magnetic flux?

$$\mu = E_F = E_v + \frac{E_g}{2} + \frac{3}{4} k_B T \ln \left(\frac{m_v^*}{m_c^*} \right)$$

$$E_F = E_v + \frac{0.514 \text{ eV}}{2} + \frac{3}{4} 8.62 \times 10^{-5} \frac{\text{eV}}{\text{K}} 300 \text{ K} \ln \left(\frac{1.5}{0.5} \right)$$

$$E_F = E_v + 0.278 \text{ eV}$$

This is very close to the middle of the band gap.

- (d) If we dope the material with an n-type dopant, what donor concentration would we have to dope to move the Fermi level to within 0.1 eV under the conduction band?

$$E_c - E_F = 0.1 \text{ eV} = E_c - \left(E_v + \frac{E_g}{2} + \frac{3}{4} k_B T \ln \left(\frac{m_v^*}{m_c^*} \right) + k_B T \ln \left(\frac{N_D}{n_i} \right) \right)$$

$$0.1 \text{ eV} = E_c - \left(E_v + 0.278 \text{ eV} + k_B T \ln \left(\frac{N_D}{n_i} \right) \right)$$

$$0.1 \text{ eV} = E_g - 0.278 \text{ eV} - k_B T \ln \left(\frac{N_D}{n_i} \right)$$

$$0.1 \text{ eV} = E_g - 0.278 \text{ eV} - k_B T \ln \left(\frac{N_D}{n_i} \right)$$

$$0.1 \text{ eV} - 0.514 \text{ eV} + 0.278 \text{ eV} = -8.62 \times 10^{-5} \frac{\text{eV}}{\text{K}} 300 \text{ K} \ln \left(\frac{N_D}{10^{15} \text{ cm}^{-3}} \right)$$

$$N_D = 1.9 \times 10^{17} \text{ cm}^{-3}$$

- (e) If we dope the material with a p-type dopant, what acceptor concentration would we have to dope to move the Fermi level to within 0.1 eV over the valence band?

$$\begin{aligned}
 E_F - E_v &= 0.1 \text{ eV} = \left(E_v + \frac{E_g}{2} + \frac{3}{4} k_B T \ln \left(\frac{m_v^*}{m_c^*} \right) - k_B T \ln \left(\frac{N_A}{n_i} \right) \right) - E_v \\
 0.1 \text{ eV} &= \left(0.278 \text{ eV} - k_B T \ln \left(\frac{N_A}{n_i} \right) \right) \\
 0.1 \text{ eV} - 0.278 \text{ eV} &= -k_B T \ln \left(\frac{N_A}{n_i} \right) \\
 0.1 \text{ eV} - 0.278 \text{ eV} &= -8.62 \times 10^{-5} \frac{\text{eV}}{\text{K}} 300 \text{ K} \ln \left(\frac{N_A}{10^{15} \text{ cm}^{-3}} \right) \\
 N_A &= 9.8 \times 10^{17} \text{ cm}^{-3}
 \end{aligned}$$

- (f) If we combine the p-type and n-type dopant from (f) and (g) together, what is the dielectric constant of the material if the depletion region width $W = 750 \text{ nm}$?

$$\begin{aligned}
 W &= \sqrt{\frac{2\epsilon_r \epsilon_0 V_{BI} N_A + N_D}{q N_A N_D}} \\
 qV_{BI} = E_{Fn} - E_{Fp} &= 0.514 - .1 - .1 \text{ eV} = 0.314 \text{ eV} \\
 V_{BI} &= 0.314 \text{ V} \\
 W &= \sqrt{\frac{2\epsilon_r \epsilon_0 V_{BI} N_A + N_D}{q N_A N_D}} \\
 750 \text{ nm} &= \sqrt{\frac{2\epsilon_r 8.85 \times 10^{-12} \frac{\text{F}}{\text{m}} 0.314 \text{ V} \quad 9.8 + 1.9}{1.6 \times 10^{-19} \text{ C} \quad 9.8 * 1.9 * 10^{17} \text{ cm}^{-3}}} \\
 \epsilon_r &= 2577
 \end{aligned}$$

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